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Substitute for form 1449A/PTO INFORMATION DISCLOSURE STATEMENT BY APPLICANT (use as many sheets necessary)		COMPLETE IF KNOWN			
		Application Number	09/932253		
		Filing Date	Aug. 16, 2001		
		First Named Inventor	Wu, et al.		
		Group Art Unit	1763		
		Examiner Name	Roberts P. Culbert		
SHEET	1	OF	2	Docket Number	LIGHT2260

U.S. PATENT DOCUMENTS						
Examiner Initials*	Cite No. ¹	U.S. Patent Document		Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number	Kind Code ² (If known)			
M	1	5,830,807		Matsunaga, et al.	11-3-1998	
M	2	5,885,881		Ojha	3-23-1999	

FOREIGN PATENT DOCUMENTS								
Examiner Initials*	Cite No. ¹	Foreign Patent Document			Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T ⁶
		Office ³	Number ⁴	Kind Code ⁵ (If known)				
M	3	PCT	WO 98/15504		Unisearch Limited	16.04.1998		
M	4	PCT	WO 98/37577		Robert Bosch	27.08.98		
M	5	PCT	WO 00/59020		University Court of the University of Glasgow	05.10.00		
M	6	UK	GB2329873		Samsung Electronics	07.04.1999		
M	7	EPO	0511448A1		International Business Machines Corporation	4.11.92		
M	8	EPO	0982606		Alcatel	01.03.00		

OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS			
Examiner Initials*	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published	T ⁶
M	9	SAYAH, A. et al., Realisation of Silicon Based Dielectric Anti-Resonant Reflecting Optical Waveguide (ARROW) on InP by Photochemical Deposition, IRPM 1996, pp. 315-318.	
M	10	SCHNEIDER, J. et al., Low Loss Corner Mirrors in InP/InGaAsP/InP for Integrated Optics Etched with Chlorinated Gases, IEEE, US, Vol. Conf. 6 No. 1, 1994, pp. 216-219.	
Examiner Signature		<i>Roberts P. Culbert</i>	Date Considered
			4/27/04

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

¹Unique citation designation number. ²See attached Kinds of U.S. Patent Documents. ³Enter Office that issued the document, by the two letter-code (WIPO Standard ST.3).

⁴For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵Kind of document by the appropriate symbols as indicated on the document under WIPO Standard St. 16 if possible. ⁶Applicant is to place a check mark here if English language translation is attached.